

**Search Notes**

Application No.

10/749,659

Examiner

Jennifer M. Kennedy

Applicant(s)

WANG, ZHONGZE

Art Unit

2812

**SEARCHED**

| Class  | Subclass | Date       | Examiner |
|--------|----------|------------|----------|
| 257    | 347-354  | 9/15/2004  | JMK      |
| 438    | 149, 151 | 9/15/2004  | JMK      |
| update |          | 10/27/2004 | JMK      |
| 438    | 455, 459 | 10/27/2004 | JMK      |
| update |          | 2/3/2005   | JMK      |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |
|        |          |            |          |

**INTERFERENCE SEARCHED**

| Class | Subclass | Date     | Examiner |
|-------|----------|----------|----------|
| 257   | 347-354  | 2/3/2005 | JMK      |
| 438   | 149, 151 | 2/3/2005 | JMK      |
| 438   | 455, 459 | 2/3/2005 | JMK      |
|       |          |          |          |

**SEARCH NOTES  
(INCLUDING SEARCH STRATEGY)**

|   | DATE       | EXMR |
|---|------------|------|
| East text   | 9/15/2004  | JMK  |
| consulted parent cases  | 9/15/2004  | JMK  |
| consulted with Erik Kielin to confirm that nitridization with NO or N2O would necessarily form a silicon oxynitride layer | 10/27/2004 | JMK  |
| update EAST text  | 10/27/2004 | JMK  |
| update  | 2/3/2005   | JMK  |
|   |            |      |
|   |            |      |
|   |            |      |